

IMiD 2018

August 28 - 31, 2018 / BEXCO, Busan, Korea

Session Title: 53. High Throughput Display Manufacturing
Date: Aug. 31 (Fri.), 2018
Time: 11:00~12:20
Room: E (Room 311~312)
Session Chairs: Dr. Chiwoo Kim (Ap systems, Korea)
Dr. Neetu Chopra (RGB OLED Programs, USA)

[E53-1]

11:00~11:25

[Invited] Multi-Material Printing for 3D Electronics

Steve Ready (Xerox Palo Research Center, USA)

[E53-2]

11:25~11:50

[Invited] Printing Technology for Display Manufacturing

Zheng Cui (Chinese Academy of Science, China)

[E53-3]

11:50~12:05

[Oral] DMD-Based Maskless Lithography for TFT-LCD

Wei He, Wusheng Li, Guangcai Yuan, and Qi Yao (BOE Tech., Group Co., Ltd., China)

[E53-4]

12:05~12:20

[Oral] Laser-Free Mechanical Debonding of Plastic Films

David Arreaga, Adrian Avendano, and Radu Reit (Ares Materials, USA)